

Micrograph Title: LOVE FOR OUR WORLD

Description: Occasionally scanning the sample, then found a piece of material naturally forming a "Heart" shape

Orig. Mag (3"x4"image): 1.57 KX Instrument : MIRA3 TESCAN Submitted by: Xinye Chen Affiliation: Rochester Institute of Technology

zvvex

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Micrograph Title: The origin of the world?

Description: Particle on a convex lens array in photoresist made with maskless grayscale lithography.

Orig. Mag (3"x4"image): 169X Instrument : Zeiss Auriga SEM Submitted by: Dominique Collé Affiliation: Heidelberg Instruments

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100 µm

zvvex

LABS

EHT = 3.00 kV WD = 8.6 mm Detector = SE2 Mag = 169 X Image Width = 677.9 μm Stage at T = 47.6 ° 2



2021 EIPBN MicroGraph Contest

Virtual Conference 2021

Micrograph Title: Newborn Silicon Nanowires

Description: Silicon nanowires nucleated and grown from the nanopores of an alumina template. This image depicts their birth, so we can watch their first moments leaving their cocoon. They grow up so fast!

Instrument : Thermo Fisher Scientific Quanta 650 FEG Submitted by: Raul Back Campanelli Affiliation: Institute of Physics "Gleb Wataghin".

Acknowledgements: Brazilian Nanotechnology National Laboratory (LNNano), FAPESP, CAPES, CNPg.

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det HV spot WD HFW mag ⊞

____ 1 µm ____



Micrograph Title: Sea of life

Description:

AFM topography of a breast cancer cell with visible absorbed nanoparticles, resembling an island in the sea. With sample courtesy: Marco Cassani PhD, FNUSA Brno, Czech republic. Orig. Mag (3"x4"image): 40 µm Instrument : LiteScope Submitted by: Radek Dao Affiliation: NenoVision s.r.o.

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2021 EIPBN MicroGraph Contest

10 µm



2021 EIPBN MicroGraph Contest

Micrograph Title: Secret-admirer to a flower

Description: The flower is a cluster of ZnO nanorods on WSe2 channel. There is a single ZnO rod on the lower left corner, which looks like a finger point to the flower.

Orig. Mag (3"x4"image): 9.30 KX Instrument : VEGA3 TESCAN Submitted by: Yulin Geng Affiliation: Institute for Integrated Micro and Nano Systems, University of Edinburgh

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SEM HV: 20.0 kV WD: 15.02 mm View field: 29.9 µm

Det: SE CEM MAC: 0.20 kg Doto/m/d/s): 02/40/04

5 um

IMMC Edinburgh University

VEGA3 TESCAN



Micrograph Title: Meteor Shower

Description: MoS2 patterns are siteselectively grown on the substrate. Different thickness of MoS2 stripes shows different darkness of color. The width of each stripe is 10µm.

Orig. Mag (3"x4"image): 10X Instrument : Nikon Eclipse LV150 Submitted by: Mingze Chen Affiliation: University of Michigan

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Micrograph Title: Crystalized squares

Description: This is a differential contrast micrograph of a Polyethylene terephthalate (PETE) imprinted with fiber-threaded rubber padding.

Orig. Mag (3"x4"image): 100x Instrument : Olympus BX60 Submitted by: Blessing Adewumi Affiliation: Louisiana State

University, Baton Rouge, USA.

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Micrograph Title: Multicolored polygons

Description: This is a differential contrast micrograph of a Polyethylene terephthalate (PETE) imprinted with fiber-threaded rubber padding. Orig. Mag (3"x4"image): 50x Instrument : Olympus BX60

Submitted by: Blessing

Adewumi

Affiliation: Louisiana State University, Baton Rouge, USA.

zyvex.

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Micrograph Title: Silicon Cheesecake

Description: Fabrication of Micro nozzle on a SOI wafer for Micro CVD.

Orig. Mag (3"x4"image): 10 KX Instrument : FIB FEI Nova 600 NanoLab Submitted by: Pavani Vamsi Krishna Nittala Affiliation: Argonne National Laboratory

& The University of Chicago Sponsored by:



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tilt HV WD mag
■ det mode HFW 52 ° 20 00 kV 5 0 mm 10 001 x ETD SE 12 8 µm

—— 5 µm



Micrograph Title: Silicon Pillars

Description: These 1 µm sized pillars fabricated using BOSCH are used to crush the biological cells

Orig. Mag (3"x4"image): 6.5 KX Instrument : FIB FEI Nova 600 NanoLab Submitted by: Pavani Vamsi Krishna Nittala

Affiliation: Argonne National Laboratory & The University of Chicago Sponsored by: **Zyvex**

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WD

45 ° 5.00 kV 4.0 mm 6 502 x ETD

tilt

Hν

mag 🎛 🛛 det 🛛 mode

HFW

SE 19.7 um

5 µm



Micrograph Title: Micro Graduation

Description: These 1 µm sized structures are fabricated using cryo etch and will be used to puncture the biological cell wall.

Orig. Mag (3"x4"image): 6.6 KX Instrument : FIB FEI Nova 600 NanoLab Submitted by: Pavani Vamsi Krishna Nittala

Affiliation: Argonne National Laboratory & The University of Chicago Sponsored by: **Zyvex**

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5 µm

tilt HV WD mag ⊫ det mode HFW 45 ° 5.00 kV 4.2 mm 6 613 x ETD SE 19.4 μm



Micrograph Title: Life in 2020

Description: These KOH based sharp silicon tips will be used to puncture the biological cell wall.

Orig. Mag (3"x4"image): 3.5 KX Instrument : SEM FEI Quanta 650 Submitted by: Pavani Vamsi **Krishna Nittala** Affiliation: Argonne National Laboratory & The University of Chicago

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LABS

7/24/2020 HV 10:46:30 AM

WD spot 10.00 kV 3.5 8.7 mm 3 555 x 10 us

mag 🎞

dwell

20 um



Micrograph Title: The Nano-code

Description: Lattice of PMMA pillars fabricated with EBL. Pillars have fallen over during exposure to solvents and have then been coated with 60 nm of Au.

Orig. Mag (3"x4"image): 23.66kX Instrument : Raith 150 Submitted by: Aran Warren Affiliation: University of Canterbury

LABS

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Micrograph Title: Pool Noodles

Description: PMMA coated with Au. Over exposed nanodot lattice using expired conductive polymer during EBL.

Orig. Mag (3"x4"image): 62kX Instrument : Raith 150 Submitted by: Aran Warren Affiliation: University of Canterbury

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Raith 150 Mag = 62.00 K X

zyvex.

LABS

200nm 0 КХ — EHT = 10.00 kV WD = 6 mm Signal A = InLens User Name = ANW41 Date :8 Jun 2020 Time :13:43:05



Micrograph Title: Dr. Seuss Coloring Book

Description: He painted this one with polymers.

Orig. Mag (3"x4"image): 500 X Instrument : Hitachi S-4500 SEM Submitted by: Jessica M. Andriolo Affiliation: Montana Tech Nanotechnology Laboratory

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MTNL 20.0kV X500 60.0,m



Micrograph Title: Where's Mickey

Description: Can you find him?

Orig. Mag (3"x4"image): 12.1 KX Instrument : Tescan Mira 3 FESEM Submitted by: Jessica M. Andriolo Affiliation: Montana Tech Nanotechnology Labora Sponsored by:

2021 EIPBN MicroGraph Contest

 SEM HV: 20.0 kV
 WD: 24.66 mm
 IIII

 View field: 11.5 μm
 Det: SE
 2 μm

 SEM MAG: 12.1 kx
 Date(m/d/v): 06/02/20
 06/02/20

MIRA3 TESCAN



Micrograph Title: Koala

Description: Hanging on to the polymer tree.

Orig. Mag (3"x4"image): 40 KX Instrument : Hitachi S-4500 SEM Submitted by: Jessica M. Andriolo Affiliation: Montana Tech Nanotechnology Laboratory

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MTNL

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2021 EIPBN MicroGraph Contest

7.0 kV X40.0K 750nm



Micrograph Title: Caught Those Dirty Bugs

Description: Electrospun Anti-Bio-Warfare-Threat Filtration System

Orig. Mag (3"x4"image): 6.66 KX Instrument : Tescan Mira 3 FESEM Submitted by: Jessica M. Andriolo Affiliation: Montana Tech Nanotechnology Labora Sponsored by:

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SEM HV: 20.0 kV	WD: 5.48 mm		M
View field: 20.8 µm	Det: SE	5 µm	
SEM MAG: 6 66 kg	Date/m/d/v): 01/23/20		

MIRA3 TESCAN



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Micrograph Title: A snowman's chance in...

Description:

We put a freshly RCA'd SOI wafer into an RTA @ 1200°C to grow 50 nm of oxide. This (and others like it) were sticking off the back side surface of the handle wafer after. We have stopped putting SOIs into the RTA...

Orig. Mag (3"x4"image): 650x Instrument : FEI Apreo Submitted by: Mark McLean and William Osborn Affiliation: NIST

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 W
 Use case
 det mode
 HFW
 WD
 curr
 mag R x:-10.8569 mm

 5.00 kV
 OptiPlan
 T2
 A+B
 195 μm
 17.5 mm
 0.20 nA
 650 x
 y:-17.9205 mm

-50 μm



Micrograph Title: Anarchy Zone

Description: Cross Hatch PCL nanofibers obtained via multi-electrode electrospinning. The fibres create a unique scene passing over each other. Rotated 180° Orig. Mag (3"x4"image): 5.82KX Instrument : TESCAN MIRA 3 Submitted by: Affiliation: Montana Technological University- MTNL

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Micrograph Title: Lunar Roving

Description: Cross Hatch PCL nanofibers obtained via multi-electrode electrospinning.

Orig. Mag (3"x4"image): 193X Instrument : TESCAN MIRA 3 Submitted by: Affiliation: Montana Technological University- MTNL

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Micrograph Title: Through Silicon Via

Description: Fabrication of 10 µm Via to a depth of 400 µm using DRIE.

Orig. Mag (3"x4"image): 0.35 KX Instrument : FIB FEI Nova 600 NanoLab Submitted by: Pavani Vamsi Krishna Nittala Affiliation: Argonne National Laboratory

& The University of Chicago Sponsored by: *zyvex*



Micrograph Title: Through Silicon Via

Description: Fabrication of 10 µm Via to a depth of 400 µm using DRIE, landed on the BOX of a SOI wafer.

Orig. Mag (3"x4"image): 2.5 KX Instrument : FIB FEI Nova 600 NanoLab Submitted by: Pavani Vamsi Krishna Nittala Affiliation: Argonne National Laboratory

& The University of Chicago Sponsored by: **Zyvex**.

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Micrograph Title: Salty Trunks

Description: NaCl crystals on aligned electrospun PCL trunks.

Orig. Mag (3"x4"image): 2.5KX Instrument : Hitachi S4500 Field Emission SEM Submitted by: Luke J. Suttey Affiliation: Montana Tech Nanotechnology Laboratory

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MTNL 20.0KV X2.50K'1

(12.0µm



Micrograph Title: Trypophobia Cave

Description: Porosity within a fractographic image of additively manufactured AISi10Mg.

Orig. Mag (3"x4"image): 360X Instrument : LEO 1430VP SEM Submitted by: Luke J. Suttey Affiliation: Montana Tech Nanotechnology Laboratory

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Sample: T22 GED: 1.50 Build Angle: 45°

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25



Micrograph Title: Aluminum Dragon Scales

Description: Metallographic image of AISi10Mg produced using additive manufacturing.

Orig. Mag (3"x4"image): 1KX Instrument : LEICA DM750M Submitted by: Luke J. Suttey Affiliation: Montana Tech Nanotechnology Laboratory

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20 µm



Micrograph Title: ET is watching...beware of the eye!

Description:

A released 75nm nitride membrane supported with random pillars. Shaded area is staining from the wet etch. The yellow lines on the sides of the image are fluidic leads. Orig. Mag (3"x4"image): 10x Instrument : Nikon L200 Compound Optical Microscope Submitted by: Alokik Kanwal Affiliation: NIST

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Micrograph Title: Alphabet

Description: Ni film deposited and melted on perforated SiO₂ surface

Orig. Mag (3"x4"image): 2 KX Instrument : see NIST declaimer Submitted by: Andrei Kolmakov Affiliation: NIST

2021 EIPBN MicroGraph Contest

 x2,000
 15.0kV
 LED
 SEM

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NIST declaimer Certain commercial products or company names are identified here to describe our study adequately. Such identification is not intended to imply recommendation or endorsement by the National Institute of Standards and Technology, nor is it intended to imply that the products or names identified are necessarily the best available for the purpose.

10µm



Micrograph Title: Neural Network

Description: PMMA graphene film placed over Cu studs and etched with oxygen plasma

Orig. Mag (3"x4"image): 5 KX Instrument : see NIST declaimer Submitted by: Andrei Kolmakov Affiliation: NIST

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1µm x5,000 15.0kV LED SEM

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Micrograph Title: Alone

Description: PDMS micro post surrounded with polystyrene microparticles

Orig. Mag (3"x4"image): 4.9 KX Instrument : see NIST declaimer Submitted by: Andrei Kolmakov Affiliation: NIST

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2 µm

ZVVEX

EHT = 10.00 kV WD = 5.9 mm Signal A = InLens Mag = 4.92 K X

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Micrograph Title: Knights of the Rectangular Table

Description: These are PDMS pillars with cobalt on top.

Orig. Mag (3"x4"image): 8 KX Instrument : FEI Quanta 3D FEG Submitted by: Zhiren Luo Affiliation: University of Texas at Austin

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Micrograph Title: Soda crackers

Description: The SU-8 mold with over exposure.

Orig. Mag (3"x4"image): 12 KX Instrument : FEI Quanta 3D FEG Submitted by: Zhiren Luo Affiliation: University of Texas at Austin

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Micrograph Title: Twisted micro-octopus

Description: Some part of PDMS pattern was peeled and twisted after RIE etching.

Orig. Mag (3"x4"image): 2 KX Instrument : FEI Quanta 3D FEG Submitted by: Zhiren Luo Affiliation: University of Texas at Austin

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33

20 µm

⌀ HV mag 및 WD curr tilt HFW 5.00 kV 1 999 x 11.3 mm 53.3 pA 45 ° 63.5 μm



Micrograph Title: Nanotrenches within microtrenches

Description: Nano- and micro-trenches in silicon.

Orig. Mag (3"x4"image): 2.8KX Instrument : Zeiss ULTRA plus Submitted by: Huseyin Ekinci Affiliation: University of Waterloo

ZYVEX.

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Width = 40.90 µm File Name = 1_1_25.tif 2 µm

Waterloo Advanced Technology Laboratory - www.WATLab.com

Mag = 2.80 K X W EHT = 10.00 kV Si

User Name = HUSEYIN

WD = 9.7 mm D Signal A = SE2 S

Date :18 Dec 2018 Time :15:27:50 System Vacuum = 1.28e-006 mbar

34

University of Waterloo Zeiss ULTRA plus



Micrograph Title: Crystal goblets set to dry

Description: Pillar fabrication in Silicon.

Orig. Mag (3"x4"image): 15KX Instrument : JEOL SEM JSM-7200F Submitted by: Huseyin Ekinci Affiliation: University of Waterloo

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v15 000

1μm QNFCF 3/2/2021 SEM WD 6 8mm 14:25:32



Micrograph Title: Whack-a-mole

Description: Fabrication of holes in microscale.

Orig. Mag (3"x4"image): 346X Instrument : Zeiss ULTRA plus Submitted by: Huseyin Ekinci Affiliation: University of Waterloo

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2021 EIPBN MicroGraph Contest

36



Width = 330.5 µm File Name = -90_4+20m_7o_23.tif

20	μm

Waterloo Advanced Technology Laboratory - www.WATLab.com

Mag = 346 X EHT = 10.00 kV WD = 6.4 mm Date :12 Jul 2019 Time :18:32:19 Signal A = InLens System Vacuum = 1.32e-006 mbar

User Name = HUSEYIN

University of Waterloo Zeiss ULTRA plus



Micrograph Title: Synchronized swimmers

Description: Etching silicon with a mask.

Orig. Mag (3"x4"image): 10KX Instrument : JEOL SEM JSM-7200F Submitted by: Huseyin Ekinci Affiliation: University of Waterloo

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2021 EIPBN MicroGraph Contest

1μm 2/9/2021 x10.000 T=20.0



Micrograph Title: Ball rolling down a hill

Description: Cleaving artifact.

Orig. Mag (3"x4"image): 14KX Instrument : JEOL SEM JSM-7200F Submitted by: Huseyin Ekinci Affiliation: University of Waterloo

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2021 EIPBN MicroGraph Contest

v14 000

15 OWV LED

1μm QNFCF 10/23/2020 SEM WD 10 4mm 14·25·27



Micrograph Title: Just Too Metal

Description: Metal deposition creeps up photoresist wall. Photoresist is completely dissolved, leaving the 3D metal structure instead of lifting off the metal like it should. 1 micron dense line/space.

Orig. Mag (3"x4"image): 12,000 magnification, 70 degree tilt Instrument : Carl Zeiss EVO 50 SEM Submitted by: Jeremy Golden / Tyler Wozmak Affiliation: KemLab Photoresist / MicroVision Labs

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Micrograph Title: Poppy / Flanders Fields

Description: Top surface of a verticallyaligned carbon nanotube forest. Erratic local growth defects lead to interesting microscopic structures.

Orig. Mag (3"x4"image): 1.76kX Instrument : Zeiss Sigma VP Submitted by: Mike Chang, Alireza Nojeh Affiliation: QMI/ECE, UBC

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2021 EIPBN MicroGraph Contest





Micrograph Title: Poppy / Flanders Fields (Colored)

Description: Top surface of a verticallyaligned carbon nanotube forest. Erratic local growth defects lead to interesting microscopic structures.

Orig. Mag (3"x4"image): 1.76kX Instrument : Zeiss Sigma VP Submitted by: Mike Chang, Alireza Nojeh Affiliation: QMI/ECE, UBC

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Micrograph Title: Abandoned Well

Description: An oversaturated micrograph of an empty hole in a carbon nanotube forest due to catalyst film defect.

Orig. Mag (3"x4"image): 7.14kX Instrument : Zeiss Sigma VP Submitted by: Mike Chang, Alireza Nojeh Affiliation: QMI/ECE, UBC

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Micrograph Title: A Fluffy Mess / Micro-Loofah

Description: A tangled up strand of carbon nanotubes.

Orig. Mag (3"x4"image): 10.03kX Instrument : Zeiss Sigma VP Submitted by: Mike Chang, Alireza Nojeh Affiliation: QMI/ECE, UBC

1 µm

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Micrograph Title: Spinnaker

Description: A broken scrap of silicon substrate resembling a spinnaker.

Orig. Mag (3"x4"image): 9.17kX Instrument : Zeiss Sigma VP Submitted by: Mike Chang, Alireza Nojeh Affiliation: QMI/ECE, UBC

1 µm

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2021 EIPBN MicroGraph Contest



Micrograph Title: Seed and Grow

Description: Not every hard work is rewarded

Orig. Mag (3"x4"image): 15KX Instrument : Verios 460L Submitted by: I-Te Chen Affiliation: The University of Texas at Austin

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2021 EIPBN MicroGraph Contest





Micrograph Title: Social Distance!

Description: This is how virus spread

Orig. Mag (3"x4"image): 15KX Instrument : Verios 460L Submitted by: I-Te Chen Affiliation: The University of Texas at Austin

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2021 EIPBN MicroGraph Contest





Micrograph Title: Nano Corn.

Description: Quantity matter!

Orig. Mag (3"x4"image): 2.5KX Instrument : Verios 460L Submitted by: I-Te Chen Affiliation: The University of Texas at Austin

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Micrograph Title: Discovering Hexagonal Ruins

Description: AIN film on SiC substrate after High Thermal Annealing in 1500°C.

Orig. Mag (3"x4"image): 20KX Instrument : ZEISS SEM LEO1530

Submitted by: Sofia Aslanidou Affiliation: IMB-CNM-CSIC / UAB

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2021 EIPBN MicroGraph Contest





Micrograph Title: Roses are Grey

Description: AIN film Sputtered on SiC Substrate.

Orig. Mag (3"x4"image): 100KX Instrument : ZEISS SEM LEO1530

Submitted by: Sofia Aslanidou Affiliation: IMB-CNM-CSIC / UAB

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Micrograph Title: One lonely tree in the sea.

Description: Cross section SEM showing the interface of Ni metal contact on N+ implanted SiC substrate.

Orig. Mag (3"x4"image): 50KX Instrument : ZEISS SEM LEO1530

Submitted by: Sofia Aslanidou Affiliation: IMB-CNM-CSIC / UAB

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